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Applicant(s)
David Mui et al.

Filing Date

Group Art Unit

		7/13/01					1765		
			<u>-</u>	U.S. PAT!	ENT DOCUMENTS				
EXAMINER INITIAL	REF		DATE		NAME	CLASS	SUBCLASS	ł	NG DATE ROPRIATE
40	1	6,037,265	3/14/00	Mui et a	al.	438	719		
	2	6,221,785	4/24/01	Tien		438	745		
Y.L	3	6,245,684	6/12/01	Zhao et	al.	438	704		
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Sheet	I	of	1	Attorney Docket Number	004227 USA 02/ETCH/SILICON/JB1

Cite No.	U.S. Patent Document		Name of Patentee or Applicant	Date of Publication of Cited Document MM-
	Number	Class/Subclass (if known)	of Cited Document	DD-YYYY
1	6,316,167 B1	430/313	Angelopoulos	11/13/2001
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				MAY 1 2 7003
				GROUD
				1700
		No. Number	No. 1 Number Class/Subclass (if known)	No. Number Class/Subclass of Cited Document (if known)

Examiner	Cite		Foreign Patent Docu	ment	Name of Patentee or Applicant of	Date of Publication of	T
Initials*	No.	Office3	Number *	Class/Subclass (if known)	Cited Document	Cited Document MM-DD- YYYY	
42	1.	EP	1 154 468 A2	H01L 21/314	Applied Materials, Inc.	11/14/2001	
9-0	2.	GB	2 346 261	H01L 21/027	NEC Corporation	08/02/2000	
20	3.	wo	99/31718	H01L 21/033	Applied Materials, Inc.	06/24/1999	
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